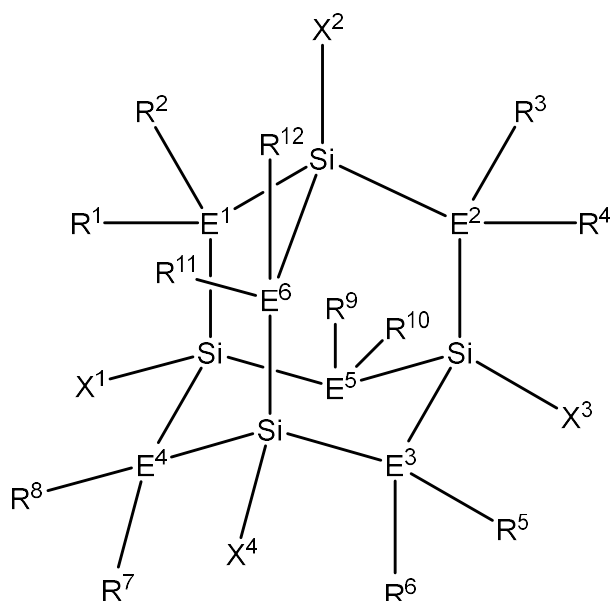


ABSTRACT

The present invention relates to a compound of formula (I)



wherein E¹ to E⁶ are independently Si or Ge; X¹ to X⁴ are independently selected from the group consisting of H, SiH₃, halogen and Si(Y)₃; Y is independently selected from C₁ to C₂₀ alkyl and halogen; R¹ to R¹² are independently selected from the group consisting of C₁ to C₂₀ alkyl, C₂ to C₂₀ alkenyl, C₂ to C₂₀ alkynyl, C₃ to C₂₀ cycloalkyl, C₆ to C₂₀ aryl, C₇ to C₂₀ arylalkyl, C₇ to C₂₀ alkylaryl and Z; and Z is independently selected from the group consisting of H, halogen and C₁ to C₂₀ alkyl; a process for their preparation; and the use of the compound for preparing the Si- and Ge-containing solid.